Docket No.: 0216-0516PUS1

Examiner: V. S. Chang

(PATENT)

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of: Toshihiko OHASHI et al.

Application No.: 10/541,776 Confirmation No.: 1474

Filed: July 8, 2005 Art Unit: 1794

For: SILICA-CONTAINING LAMINATED

STRUCTURE, AND COATING

COMPOSITION FOR USE IN FORMING A

POROUS SILICA LAYER

DO NOT ENTER: /V.C./

## AMENDMENT IN RESPONSE TO NON-FINAL OFFICE ACTION

MS Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

## **INTRODUCTORY COMMENTS**

In response to the Office Action dated April 24, 2008, please amend the above-identified U.S. patent application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 9 of this paper.